

EAST Search History**EAST Search History (Prior Art)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	27	(stage table wst) near (substrate wafer object) and (lyophilic hydrophilic liquidphilic philic affinity) near (recover\$1)	US_PGPUB; USPAT; USOOR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/02/25 17:11
L2	59	(stage table support chuck) near (substrate wafer object workpiece) same (lyophilic hydrophilic liquidphilic philic affinity) with (recover\$3 remov \$3)	US_PGPUB; USPAT; USOOR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/02/25 17:11
L3	20	(stage table support chuck) near (substrate wafer object workpiece) same (lyophilic hydrophilic liquidphilic philic affinity) with (recover\$3 remov \$3) and (\$5lithograph\$2 exposure).ti.	US_PGPUB; USPAT; USOOR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/02/25 17:11

L4	0	(stage table support chuck) near (substrate wafer object workpiece) same (lyophilic hydrophilic liquidphilic philic affinity) with (protrud\$3 overhang\$3) and (\$5lithograph\$2 exposure).ti.	US_PGPUB; USPAT; USOOR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/02/25 17:11
L5	48	(stage table support chuck) near (substrate wafer object workpiece) same (protrud\$3 overhang\$3) same (recover\$3 remov \$3) and (\$5lithograph\$2 exposure).ti.	US_PGPUB; USPAT; USOOR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/02/25 17:11
L6	39	(stage table support chuck) near (substrate wafer object workpiece) same (protrud\$3 overhang\$3) same (recover\$3 remov \$3) with (liquid fluid immersion) and (\$5lithograph \$2 exposure).ti.	US_PGPUB; USPAT; USOOR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/02/25 17:11

2/25/2011 5:13:03 PM

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